

Supplementary Materials



# Using *in Situ* Polymerization to Increase Puncture Resistance and Induce Reversible Formability in Silk Membranes

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Received: 24 April 2020; Accepted: 11 May 2020; Published: date

FTIR Spectra for all samples

AFM Images of all samples

Puncture testing of silk membranes

Images of Contact Angle for each Silk Membrane treatment

**Reflectance Spectroscopy** 

Figure 9 from Manuscript (Enlarged)

#### FTIR Spectra for all samples.

All spectra are overlaid from one sample with each spectrum acquired from a different location on the silk membrane.



Figure S1. Untreated membrane.



Figure S2. Control membrane.



Figure S3. 4-Nitrobenzene tetrafluoroborate treated membrane.



Figure S4. 4-Cyanobenzene tetrafluoroborate treated membrane.



Figure S5. 4-Ethynylbenzene tetrafluoroborate treated membrane.



Figure S6. 3-(Trifluoromethyl)benzene tetrafluoroborate treated membrane.

#### **AFM Images of all samples**

All images are obtained from a 50 nm  $\times$  50 nm section of silk membrane.



Figure S7. Untreated membrane.



Figure S8. Control Membrane.



Figure S9. 4-Nitrobenzene tetrafluoroborate treated membrane.



Figure S10. 4-Cyanobenzene tetrafluoroborate treated membrane.



Figure S11. 4-Ethynylbenzene tetrafluoroborate treated membrane.



Figure S12. 3-(Trifluoromethyl)benzene tetrafluoroborate treated membrane.

### Puncture testing of silk membranes

All images are obtained from a 50 nm  $\times$  50 nm section of silk membrane.



Figure S13. Untreated membrane.







Figure S15. 4-Nitrobenzene tetrafluoroborate treated membrane.



Figure S16. 4-Cyanobenzene tetrafluoroborate treated membrane.



Figure S17. 4-Ethynlbenzene tetrafluoroborate treated membrane.



Figure S18. 3-(Trifluoromethyl)benzene tetrafluoroborate treated membrane.



Figure S19. Schematic for Needle puncture apparatus.

## Images of Contact Angle for each Silk Membrane treatment



Figure S20. Untreated Membrane.



Figure S21. Control Membrane.



Figure S22. 4-Nitrobenzene tetrafluoroborate treated membrane.



Figure S23. 4-Cyanobenzene tetrafluoroborate treated membrane



Figure S24. 4-Ethynylbenzene tetrafluoroborate treated membrane.



Figure S25. 3-(Trifluoromethyl)benzene tetrafluoroborate treated membrane.

#### **Reflectance Spectroscopy**

Reflection measurements were conducted with an Ocean Optics STS-VIS Miniature Spectrometer using SpectraSuite software. An Ocean Optics QR400-7-VIS-NIR 2 m reflection probe was coupled with an Ocean Optics HL-2000-FHSA tungsten halogen light source and the spectrometer to complete the reflection setup. A reflection probe holder was used to position the probe at an angel of 90°, with the face of probe placed approximately 3 mm from the surface of the silk samples. Once the reflection measurements were conducted, the spectra were then exported to Excel for graphing.



**Figure S26.** (a) Untreated membrane; (b) Control Membrane; (c) 4-Nitrobenzene tetrafluoroborate treated membrane; (d) 4-Cyanobenzene tetrafluoroborate treated membrane; (e) 4-Ethynylbenzene tetrafluoroborate treated membrane; (f) 3-(Trifluoromethyl)benzene tetrafluoroborate treated membrane.

#### Figure 9 from Manuscript (Enlarged)



Figure S27. (a) Schematic of the proposed mechanism of malleability; (b) Photos corresponding to each phase in the schematic.



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